

## 《基于微纳光纤双模式干涉的亚波长聚焦光场及光捕获应用》 的补充材料

吴婉玲 王向珂 虞华康<sup>†</sup> 李志远

(华南理工大学物理与光电学院, 广州 510641)

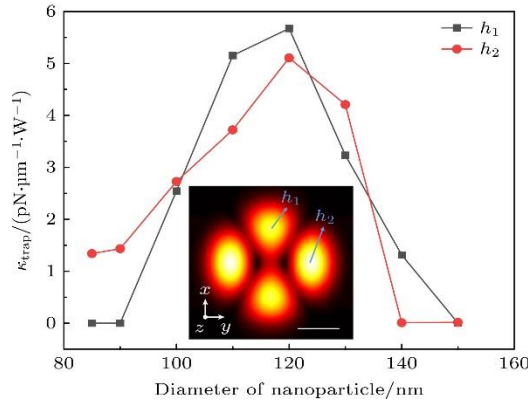


图 S1 模式组  $\text{HE}_{11} + \text{EH}_{11}$  的聚焦光场捕获不同直径的纳米颗粒时的捕获刚度. 插图为聚焦光场在焦平面上的电场分布  $|\mathbf{E}|$ , 黑色方点为焦点  $h_1$  (在  $xy$  平面上位于  $(x, y) = (0.5, 0) \mu\text{m}$ ) 的捕获效果; 红色圆点为焦点  $h_2$  (在  $xy$  平面上位于  $(x, y) = (0, 0.44) \mu\text{m}$ ) 的捕获效果

Fig. S1. Trapping stiffness for 85 nm polystyrene (PS) nanoparticles versus diameters under the two-mode interference of  $x$ - $\text{HE}_{11}$  and even- $\text{EH}_{11}$ . Considering a nanoparticle located at a position of  $(x, y) = (0.5, 0) \mu\text{m}$  (black dots) and  $(x, y) = (0, 0.44) \mu\text{m}$  (red dots) respectively, longitudinal forces could be calculated by moving nanoparticles along the  $z$ -direction. Thus, one obtained  $\kappa_{\text{trap}}$  via the slopes of longitudinal forces near the trapping equilibrium position. The inset shows the  $\mathbf{E}$ -field in the focal plane, where two kinds of foci were referred to as  $h_1$  and  $h_2$ .

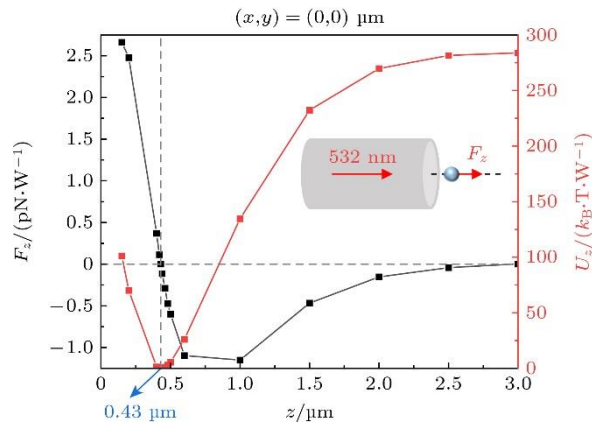


图 S2 准  $x$  线偏振态模式组  $\text{HE}_{11}$  和  $\text{HE}_{12}$  的聚焦光场对 PS 颗粒的纵向捕获强度 (黑色曲线为纵向光力; 红色曲线为势能. 插图 of 计算模型)

Fig. S2. Longitudinal trapping strength for an 85 nm PS particle under two-mode interference of  $x$ -polarized  $\text{HE}_{11}$  and  $\text{HE}_{12}$  (Longitudinal force (black curve) and potential energy (red curve) along the fiber axis. The inset shows the calculated model).

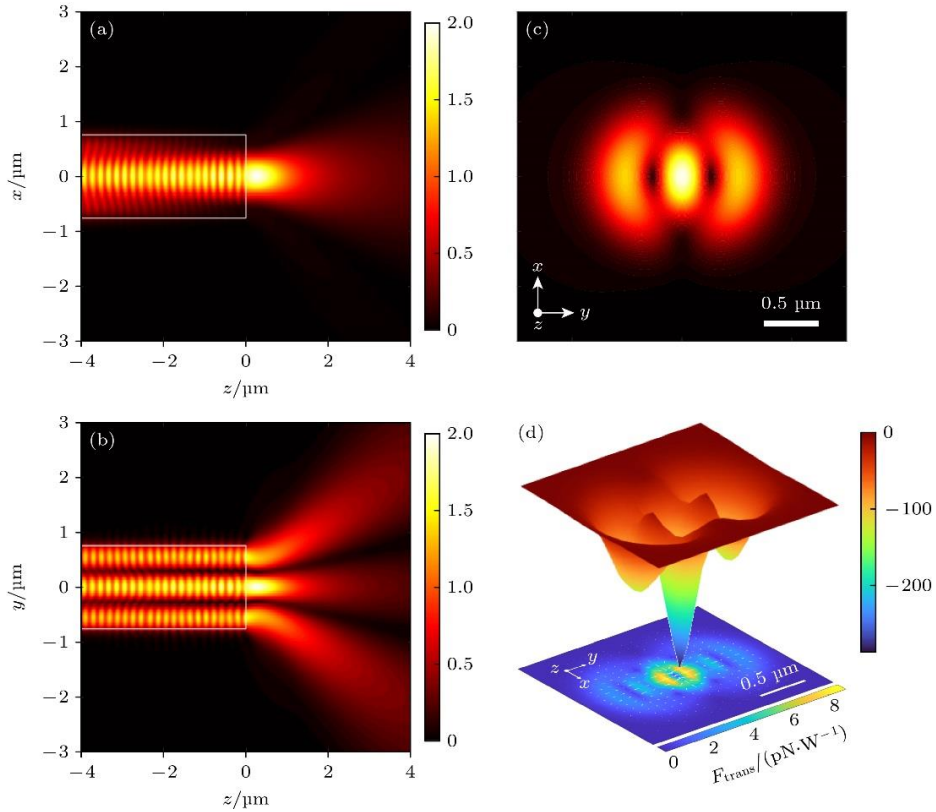


图 S3 模式组  $HE_{11} + HE_{12}$  的聚焦光场及对直径 85 nm 的 PS 颗粒的捕获强度 (a)  $xz$  平面; (b)  $yz$  平面; (c) 焦平面上的电场强度的模值分布 ( $|\mathbf{E}|$ ), 单位为 V/m. (d) 捕获平面上的势能密度分布 (三维图) 和横向光力分布 (底部的二维图), 其中势能单位为  $k_B T/W$ 、光力单位为 pN/W. 图(c), (d)中比例尺为  $0.5 \mu\text{m}$

Fig. S3.  $\mathbf{E}$ -field and trapping strength for an 85 nm PS particle under two-mode interference of even- $HE_{11}$  and  $x$ - $HE_{12}$ .  $\mathbf{E}$ -fields in (a), (b) the central cross-sections ( $xz$  and  $yz$  planes) and (c) the focal plane ( $xy$  plane at  $z = 0.25 \mu\text{m}$ ) have a unit of V/m. Solid rectangles depict microfiber profiles. (d) Potential energy densities (3D profile) in trapping planes, with a unit of  $k_B T/W$ . The image below shows the transverse force exerted on the nanoparticle in the trapping plane: the color scale indicates the magnitude of the force and the arrows indicate its direction. The scale bars in panels (c) and (d) are  $0.5 \mu\text{m}$ .

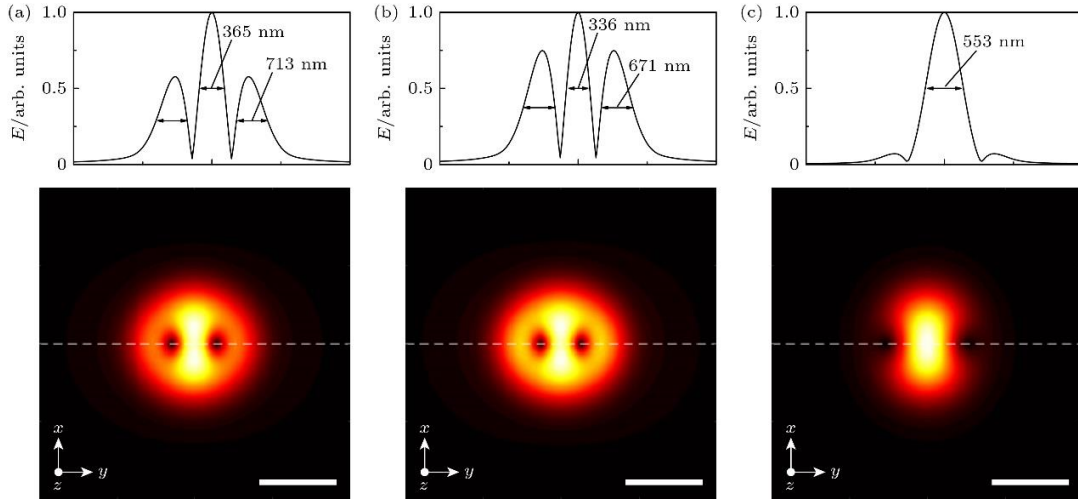


图 S4 模式组  $HE_{11} + EH_{11}$  在不同相对功率比下的归一化电场强度,  $HE_{11}$  模式的功率保持 1.04419 fW (a)  $P_{HE} : P_{EH} = 1 : 5.28$ ; (b)  $P_{HE} : P_{EH} = 1 : 11.88$ ; (c)  $P_{HE} : P_{EH} = 3 : 1$

Fig. S4. Normalized  $E$ -field of interference pattern via the two-mode set of  $x$ - $HE_{11}$  and even- $EH_{11}$  with diverse power ratios, one kept the power of  $x$ - $HE_{11}$  mode to be 1.04419 fW: (a)  $P_{HE} : P_{EH} = 1 : 5.28$ ; (b)  $P_{HE} : P_{EH} = 1 : 11.88$ ; (c)  $P_{HE} : P_{EH} = 3 : 1$ .

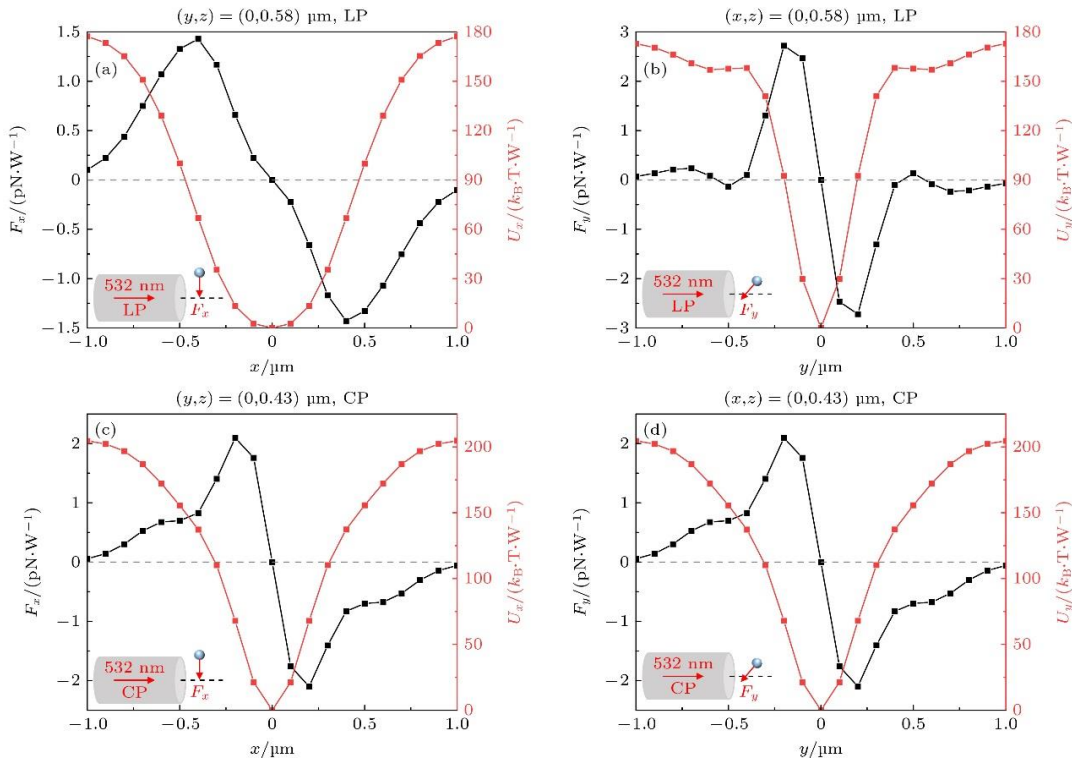


图 S5 模式组  $HE_{11} + EH_{11}$  的聚焦光场捕获直径 85 nm 的 PS 颗粒时的横向效果(黑色曲线为纵向光力; 红色曲线为势能; 插图为计算模型) (a), (b) 线偏振态模式组; (c), (d) 圆偏振态模式组。

Fig. S5. Transverse trapping strength for an 85 nm PS particle under the two-mode interference of  $x$ - $HE_{11}$  and even- $EH_{11}$  (Transverse force (black curves) and potentials (red curves) in trapping planes under (a), (b) linear and (c), (d) circular polarization excitation. The insets show the calculated models).